CERN MPT workshop DRD1-WG6 20/06/2024

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- Vacuum deposition machine
- DLC deposition status
- uRgroove detectors

Machine configuration reminder



Drum: 55cm diameter 70cm height 1.7m circumference

Substrate

shutters

holder

• Test samples to tune the recipes

- Vertical samples, 60 x 10 cm2
- APICAL NP polyimide 50um thick
- Sample preparation \rightarrow drying 220 deg for 4 days

• Main steps during a RUN

1/ Ar based plasma sample cleaning
2/ Ar based plasma + graphite target cleaning
3/ Ar/C2H2 plasma + graphite target cleaning
4/ Ar/C2H2 plasma + final sputtering process

Post RUN

- Direct resistivity measurements
- Baking samples to stabilize the value
- Monitoring of the resistivity during the following days (stability check)



3 deposition methods Oscillation/step by step/rotation

Oscillation: Adjustable angle : 0 to +/-90deg Adjustable speed Adjustable time



Step by step: 0 to 360 deg Adjustable steps Adjustable static time

Ex: -25 to +25 in 10 steps of 90s

Rotation: Constantly rotating Adjustable drum speed Adjustable time

1 - Sample cleaning:

Shutter closed Target power: off RF power : 500W t = 600 sec Ar = 150ml/min

→ RF power stopped for 15s to evacuate species in the chamber

2 - Target pre-sputtering cleaning:

Shutter closed Target power: 500W RF power : 300W t = 300 sec Ar = 150ml/min

3- Pre-sputtering @ nominal parameters

Shutter closed Target power : 1200W RF power : 500W t = 60 sec Ar = 200ml/min C2H2= 2ml/min

→RF and Target power stopped for 15s to evacuate species in the chamber

ightarrow open the shutters

4 - DLC deposition :

Target power : 1200 W RF power : 500 W t = 900 sec Ar = 200ml/min C2H2= 2ml/min Chamber pressure : 5.10⁻³ m.bar. Drum speed 1 turn/min Oscillation : +25deg to -25deg Chamber pressure regulation 52% of the maximum



RF power profil during DLC coating



P = 5.10 - 3mbarAr = 200ml/l $C_2H_2 = 2ml/l$ RF power = 500W t = 900s deposition time These are typical curves: Test samples should be produced before each production to fine tune.

A large range of resistive values can be reached: -10K to 10G





The repeatability is obviously much better if no water is present during deposition . We are now drying the foils 4 days at 220°C , this treatment is probably excessive .

We got problems to apply this baking cycle to APICAL with copper on one side. Tests are going on to reduce temperature and optimize the time to reach the optimum drying.

From the document : Moisture pick-up and minimum drying conditions from ESA, I have extracted the following info :

-At 120 deg the PI should be sufficiently dry after 5 days .

-120 deg/12hours correspond to 105 deg/48 hours

-rule : the time should be multiplied by 2 each time the temperature is reduced by 7.5 deg.

Post baking

Resistivities are divided by 2 after baking 2h 220deg.

Except thinner layer with high values (????).



Blue before baking Orange after baking



as expected, good homogeneity along the 1.7m axis



Second large foil - 1700mm×610mm - DLC \approx 60 M Ω +/-30% over 45cm

60cm

148ΜΩ				
58ΜΩ	69ΜΩ	68ΜΩ	73ΜΩ	81ΜΩ
48MΩ	42ΜΩ	43ΜΩ	48ΜΩ	49ΜΩ
80ΜΩ	77ΜΩ	75ΜΩ	68ΜΩ	70ΜΩ
238ΜΩ	265ΜΩ	202ΜΩ	196ΜΩ	201ΜΩ

1.7m

Situation with DLC coatings

- <u>DLC on APICAL NP 50um for medium rate Micromegas</u>
 - tests nearly finished \rightarrow detectors in production
 - Up to 600mm × 600mm OK
 - Need some more tests to stabilize 1.7m x 0.6m
- <u>DLC/Cr/Cu on APICAL NP 50um for high rate Micromegas</u>
 - tests nearly finished \rightarrow perfect adhesion \rightarrow detectors in production
 - Up to 600mm x 600mm OK
 - Need some more tests to stabilize 1.7m x 0.6m
- DLC on APICAL NP 50um with 5um on one side for high rate uRwells or uRgrooves
 - Still need some time to improve repeatability \rightarrow pre-drying optimisation
 - Detectors in production soon
- Improved DLC uniformity.
 - Target \rightarrow +/-10% over 60cm instead of the present +/-30% over 45cm
 - We will start soon; and we have good ideas
 - Mask on the shutter \rightarrow there is an effect but not fully satisfactory
 - Mask on the target \rightarrow to be tested



Mask deposition done this week by Frascati team 3GOhms/square Polyimide mask





1999→Micro-Well (Ronaldo Bellazzini)



-3 x 3 cm Micro-well detector -Produced at MPT with GEM processes -Really simple but abandoned due to the difficulty to mitigate sparks



Close-up view Square pattern used in the early days





A year before→Micro-Groove (Ronaldo Bellazzini)

The idea to cross the lines at 90deg was not yet envisaged. \rightarrow MSGC heritage





2015→Resistive layer introduction (Giovanni Bencivenni)



Polyimide coated foil: copper top , DLC bottom



uRgrooves \rightarrow good space resolution , less production steps , perfect X/Y ratio , less material , -Possibility to reduce strips capacity by reducing the width of Y and X strips (TBC).

Design of 10cm×10cm uRgrooves prototypes (Siqi He's slide , Zhou Yi team) (detector produced @CERN)



- Two version prototypes of 10cm×10cm
- **Groove pitch: 200μm, 2 grooves are connected making 1 strip**
- > 2D-version, Y and X pitch: 400µm
- ➢ 3D-version, X/Y/V pitch: 400µm , V angle: 45°
- \blacktriangleright Verify μ RGroove structure and charge sharing effect.







50cm×50cm 2D-µRGroove

(Siqi He's slide, Zhou Yi team) (detector produced @CERN)



- The central 10cm×10cm area is connected to the electronic system for testing with the rest readout strips grounded
- Same setup of beam test



Dead Area (TOP): 2/128=1.5625%

Cylindrical-µRGroove: Manufacture

(Siqi He's slide, Zhou Yi team) (detector parts produced @CERN)



✓ Total material budget: ~0.23%X₀

Electrical cleaning

-Improves the max voltage (typ: from 580V to 670V in hot air@90deg).

-It materializes the places with high parasitic fields.

-It is a powerful tool to optimize the detector design.

After 2mA constant cleaning current at 680V during a full week



DLC removed by electro cleaning , the fields are clearly higher at this location.
-The detector at the end was operational and the maximum voltage have been recovered.
-Based on this observation we have optimized the layout → we have kept the polyimide hiding the DLC at this location.



DLC Removed \rightarrow the field on the last strip is higher \rightarrow conclusion : we must also keep the Kapton at this location.



DLC a bit removed \rightarrow conclusion : in the active area we must keep constant grooves of 70um -It would be nice to confirm all these observation with Comsol.

Beam test: Result of 2D-µRGroove (10cm x10cm) improved layout (Siqi He's slide, Zhou Yi team)



The detector is slightly tilted due to setup issues

Gas mixture during this test beam : Ar/C4H10 (90/10). Possible other gas mixture: Ar/CO2/CF4 (45/15/40). Also recently tested with same results : Ar/C4H10 (98/2), nonflammable.



- Drift electric field is 2kV/cm with 5mm gas gap.
 - ✓ The combined efficiency is about 97.9% and enter plateau at ~410V
 - ✓ Spatial resolution is ~76µm for top readout and 70µm for bot readout
 - ✓ Charge radio of X/Y is about 1.013

Conclusions

- We have made good progresses with DLC deposition. We are about to finish optimizations.
- Large foils of 1.7m x 0.6m can be produced.
- We know now that we can reach a throughput of 3 to 4 large foils per day.
- uRgroove detectors seems to beat uRwell detectors on many aspects.



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